

# Subject Name Solutions

1313202 – Summer 2023

Semester 1 Study Material

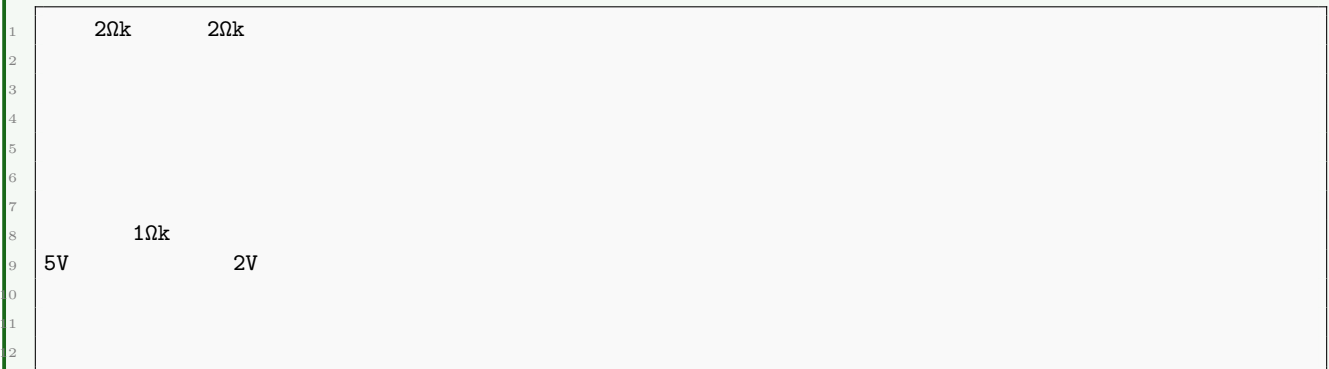
*Detailed Solutions and Explanations*

## Question 1(a) [3 marks]

Find mesh currents in following circuit.

### Solution

Diagram/Table:



Applying Mesh Analysis:

- Write KVL equations for two meshes
- $I_1$  flows clockwise in left loop
- $I_2$  flows clockwise in right loop

Steps to solve:

- **Mesh 1 equation:**  $5V - 2k\Omega I_1 - 1k \times (I_1 - I_2) = 0$
- **Mesh 2 equation:**  $-2V + 2k\Omega I_2 + 1k \times (I_2 - I_1) = 0$

Simplifying:

- $5 - 2000I_1 - 1000I_1 + 1000I_2 = 0$
- $-2 + 2000I_2 + 1000I_2 - 1000I_1 = 0$
- $3000I_1 - 1000I_2 = 5$
- $-1000I_1 + 3000I_2 = 2$

Solving:  $I_1 = 2mA$ ,  $I_2 = 1mA$

### Mnemonic

“Mesh Matters: Write KVL, Solve Simultaneous”

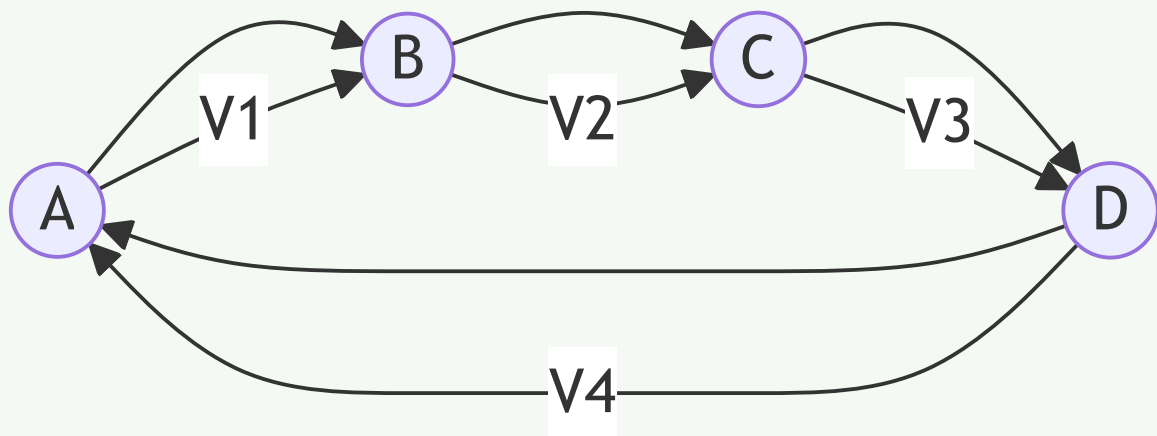
## Question 1(b) [4 marks]

State and explain Kirchhoff's Voltage Law (KVL) with the help of diagram.

### Solution

Kirchhoff's Voltage Law (KVL) states that the algebraic sum of all voltages around any closed loop in a circuit is zero.

**Diagram:**



#### Key points:

- **Loop rule:**  $V_1 + V_2 + V_3 + V_4 = 0$
- **Sign convention:** Voltage rise (battery positive terminal) is positive, voltage drop (across resistor) is negative
- **Conservation principle:** Total energy gained equals total energy lost in any closed loop
- **Application:** Used to analyze and solve complex circuits with multiple voltage sources

#### Mnemonic

“Voltages Around a Loop Sum to Zero” (VALSZ)

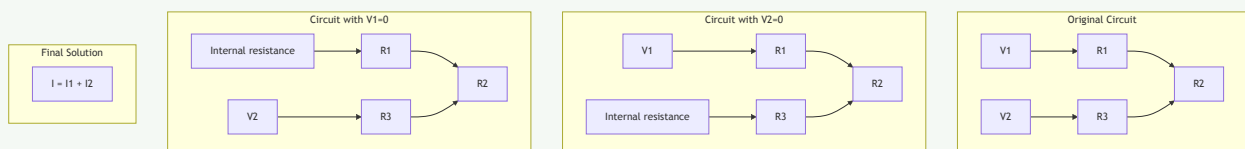
### Question 1(c) [7 marks]

State and explain Superposition theorem.

#### Solution

Superposition theorem states that in a linear circuit with multiple sources, the response in any element is the sum of responses caused by each source acting alone, with all other sources replaced by their internal impedances.

**Diagram:**



#### Steps to apply:

- **Step 1:** Consider one source at a time
- **Step 2:** Replace voltage sources with short circuits ( $0\Omega$ )
- **Step 3:** Replace current sources with open circuits ( $\infty$ )
- **Step 4:** Calculate the response (voltage/current) due to each source
- **Step 5:** Add all responses algebraically to get total response

#### Applications:

- **Circuit analysis:** Simplifies complex circuits with multiple sources
- **Network theory:** Foundation for more advanced analysis methods
- **Practical circuits:** Analyzing superimposed signals in communication systems

#### Mnemonic

“Sources Separately, Sum Successfully” (SSSS)

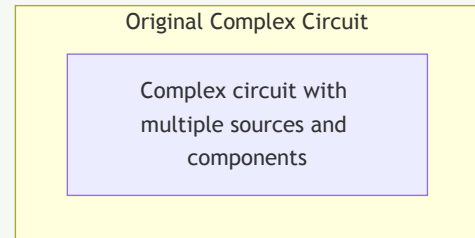
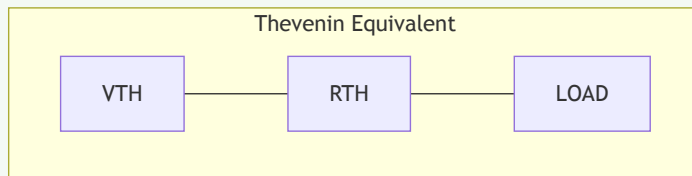
### Question 1(c) OR [7 marks]

State and explain Thevenin's theorem.

#### Solution

Thevenin's theorem states that any linear circuit with voltage and current sources can be replaced by an equivalent circuit consisting of a voltage source ( $V_{TH}$ ) in series with a resistance ( $R_{TH}$ ).

**Diagram:**



**Steps to find Thevenin equivalent:**

- **Step 1:** Remove load resistor from original circuit
- **Step 2:** Calculate open-circuit voltage ( $V_{OC}$ ) across load terminals ( $= V_{TH}$ )
- **Step 3:** Calculate equivalent resistance ( $R_{TH}$ ) by:
  - Deactivating all sources (replacing voltage sources with short circuits and current sources with open circuits)
  - Finding resistance between load terminals

**Applications:**

- **Circuit simplification:** Reduces complex networks to simple equivalent
- **Load analysis:** Easily calculate effects of changing loads
- **Maximum power transfer:** Determine conditions for maximum power

#### Mnemonic

"Two Handy Elements: Voltage and Resistance" (THEVR)

### Question 2(a) [3 marks]

Give comparison of trivalent, tetravalent and pentavalent materials.

#### Solution

Property	Trivalent Materials	Tetravalent Materials	Pentavalent Materials
<b>Valence electrons</b>	3	4	5
<b>Examples</b>	Boron, Aluminum, Gallium	Silicon, Germanium, Carbon	Phosphorus, Arsenic, Antimony
<b>Doping type</b>	Used as P-type dopants	Base semiconductor materials	Used as N-type dopants
<b>Bond formation</b>	Makes 3 covalent bonds	Makes 4 covalent bonds	Makes 5 covalent bonds
<b>Charge carriers</b>	Creates holes (positive)	Creates balanced structure	Creates free electrons (negative)

#### Mnemonic

"Three-Four-Five: Holes-Balance-Electrons" (TFF:HBE)

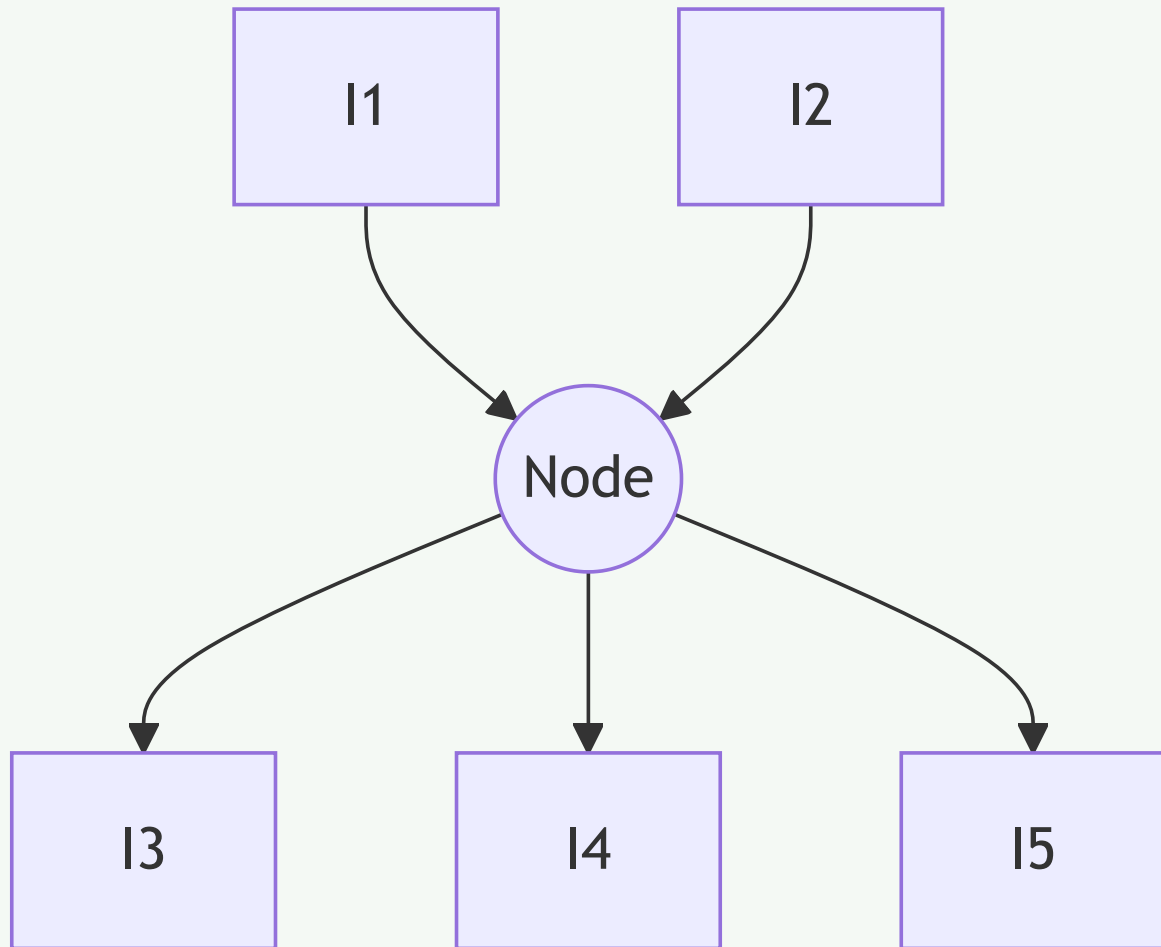
### Question 2(b) [4 marks]

State and explain Kirchhoff's Current Law (KCL) with the help of diagram.

### Solution

Kirchhoff's Current Law (KCL) states that the algebraic sum of all currents entering and leaving any node in an electrical circuit is zero.

**Diagram:**



**Key points:**

- **Node equation:**  $I_1 + I_2 - I_3 - I_4 - I_5 = 0$  (or  $I_1 + I_2 = I_3 + I_4 + I_5$ )
- **Sign convention:** Currents entering node are positive, leaving are negative
- **Conservation principle:** Based on conservation of electric charge
- **Application:** Essential for solving circuits with parallel components

### Mnemonic

“Currents In Equals Currents Out” (CIECO)

### Question 2(c) [7 marks]

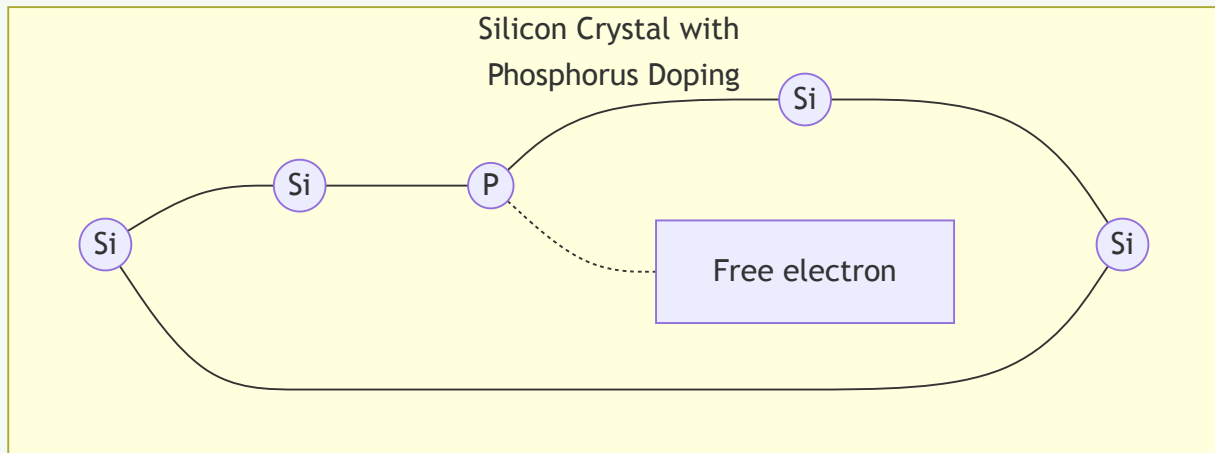
**Define: Extrinsic Semiconductor.** Explain formation of N-type Semiconductor with the help of diagram.

### Solution

**Extrinsic Semiconductor:** A semiconductor whose electrical properties are modified by adding impurity atoms (doping) to change its conductivity.

**N-type Semiconductor Formation:**

**Diagram:**



**Process:**

- **Doping process:** Pentavalent impurity (P, As, Sb) added to tetravalent semiconductor (Si, Ge)
- **Bond formation:** Impurity atom forms 4 covalent bonds with neighboring Si atoms
- **Free electron:** 5th electron has no bond to form and becomes free to move
- **Charge carriers:** Majority carriers are electrons, minority carriers are holes
- **Conductivity:** Higher than intrinsic semiconductor due to more free electrons

**Properties of N-type semiconductor:**

- **Fermi level:** Closer to conduction band
- **Donor level:** Energy level created near conduction band
- **Room temperature:** Most donor atoms are ionized

**Mnemonic**

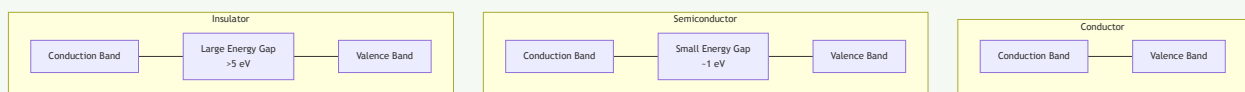
“Phosphorus Provides Plus-one electron” (PPP)

**Question 2(a) OR [3 marks]**

Draw energy band diagrams for Conductor, Semiconductor and Insulator.

**Solution**

**Diagram:**



**Key characteristics:**

- **Conductor:** Overlapping bands or partially filled band
- **Semiconductor:** Small energy gap (~1 eV)
- **Insulator:** Large energy gap (>5 eV)

**Mnemonic**

“Gaps Determine Flow: None, Small, Huge” (GDF:NSH)

**Question 2(b) OR [4 marks]**

Give the difference between EMF and Potential difference.

### Solution

Parameter	EMF (Electromotive Force)	Potential Difference
<b>Definition</b>	Energy supplied per unit charge by a source	Energy consumed per unit charge in a component
<b>Symbol &amp; Unit</b>	or E, measured in Volts	V, measured in Volts
<b>Cause</b>	Chemical, mechanical, thermal or light energy conversion	Result of current flowing through a resistance
<b>Measurement</b>	Measured across source terminals with no current flowing	Measured across components when current flows
<b>Direction</b>	From negative to positive inside source	From positive to negative outside source
<b>Device example</b>	Battery, generator, solar cell	Resistor, lamp, motor
<b>Conservation</b>	Not conserved in a circuit	Conserved in a closed circuit (KVL)

### Mnemonic

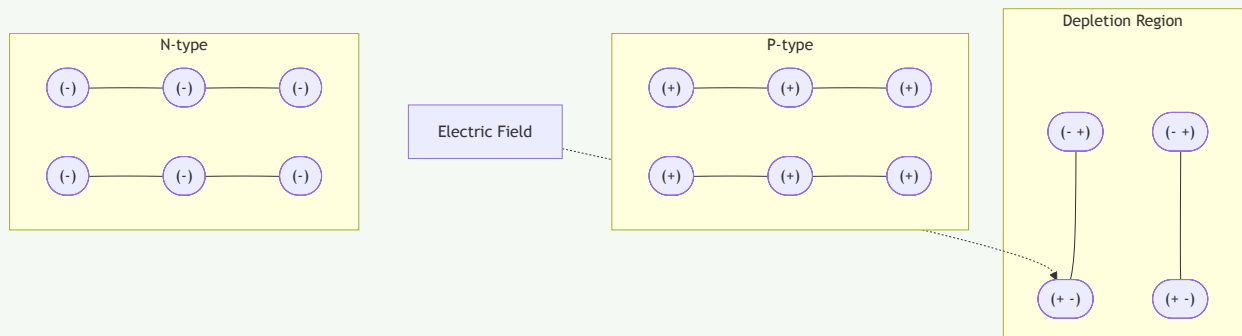
“EMF Creates, PD Consumes” (ECPC)

### Question 2(c) OR [7 marks]

Explain the formation of depletion region or space-charge region in P-N junction.

### Solution

**Diagram:**



**Formation process:**

- **Junction creation:** When P-type and N-type semiconductors are joined
- **Diffusion:** Free electrons from N-side diffuse to P-side; holes from P-side diffuse to N-side
- **Recombination:** Electrons recombine with holes near junction
- **Ion formation:** Immobile positive ions left in N-region; negative ions in P-region
- **Electric field:** Created across the junction pointing from N to P
- **Equilibrium:** Diffusion current balanced by drift current due to electric field
- **Barrier potential:** Typically 0.7V for silicon, 0.3V for germanium

**Characteristics:**

- **Width:** Typically 0.5 mm, depends on doping concentration
- **Capacitance:** Acts as variable capacitor
- **Barrier:** Prevents further diffusion of majority carriers

### Mnemonic

“Diffusion Creates, Field Balances” (DCFB)

### Question 3(a) [3 marks]

Define forbidden energy gap. How does it occur? What is its magnitude for Ge and Si?

### Solution

**Forbidden energy gap** is the energy range between valence band and conduction band where no electron energy states exist in a semiconductor.

**Occurrence:**

- Results from quantum mechanical interaction of atoms in crystal lattice
- Forms due to splitting of energy levels when atoms are brought close together
- Creates band structure with allowed and forbidden regions

**Magnitude:**

- **Germanium (Ge):** 0.67 eV at 300K
- **Silicon (Si):** 1.1 eV at 300K

### Mnemonic

“Greater Silicon, Lower Germanium” (GSLG)

### Question 3(b) [4 marks]

Define the following terms: (i) Knee voltage (ii) Reverse saturation current (iii) Reverse breakdown voltage (iv) Peak Inverse Voltage (PIV)

### Solution

**Table of Definitions:**

Term	Definition
<b>Knee voltage</b>	The forward voltage at which current through diode starts increasing rapidly (0.3V for Ge, 0.7V for Si)
<b>Reverse saturation current</b>	The small current that flows when diode is reverse biased, due to minority carriers (typically nA or $\mu$ A)
<b>Reverse breakdown voltage</b>	The reverse voltage at which the diode conducts heavily in reverse direction due to breakdown mechanisms
<b>Peak Inverse Voltage (PIV)</b>	Maximum reverse voltage a diode can withstand without breakdown in a rectifier circuit

### Mnemonic

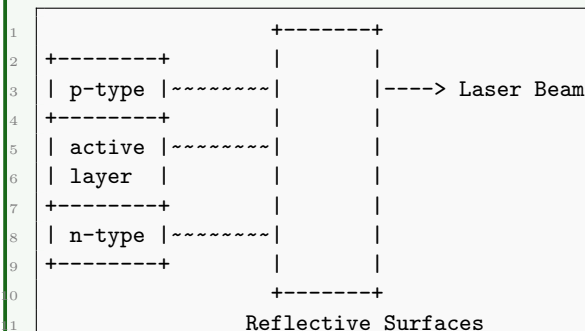
“Knee Rises, Saturation Trickles, Breakdown Bursts, PIV Protects” (KRSBBP)

### Question 3(c) [7 marks]

Explain construction, working and characteristics of LASER diode and write its applications.

### Solution

**Diagram:**



**Construction:**

- **P-N junction:** Made of direct bandgap semiconductor (GaAs, InGaAsP)
- **Active region:** Thin layer between P and N regions where recombination occurs

- **Cavity design:** Parallel reflective surfaces (cleaved facets) form optical resonator
- **Packaging:** Includes heat sink, optical window, monitoring photodiode

#### Working principle:

- **Injection:** Forward biasing injects electrons and holes into active region
- **Population inversion:** More electrons in excited state than ground state
- **Stimulated emission:** Photon triggers release of identical photons (same wavelength, phase)
- **Optical feedback:** Photons reflect between mirrors, amplifying light
- **Threshold current:** Minimum current for lasing action

#### Characteristics:

- **Coherent light:** Single wavelength, in-phase light emission
- **Directionality:** Highly directional, narrow beam
- **High intensity:** Concentrated energy output
- **Threshold behavior:** Laser action only above threshold current

#### Applications:

- Optical fiber communications
- DVD/Blu-ray players
- Laser printers
- Barcode scanners
- Medical surgery instruments

#### Mnemonic

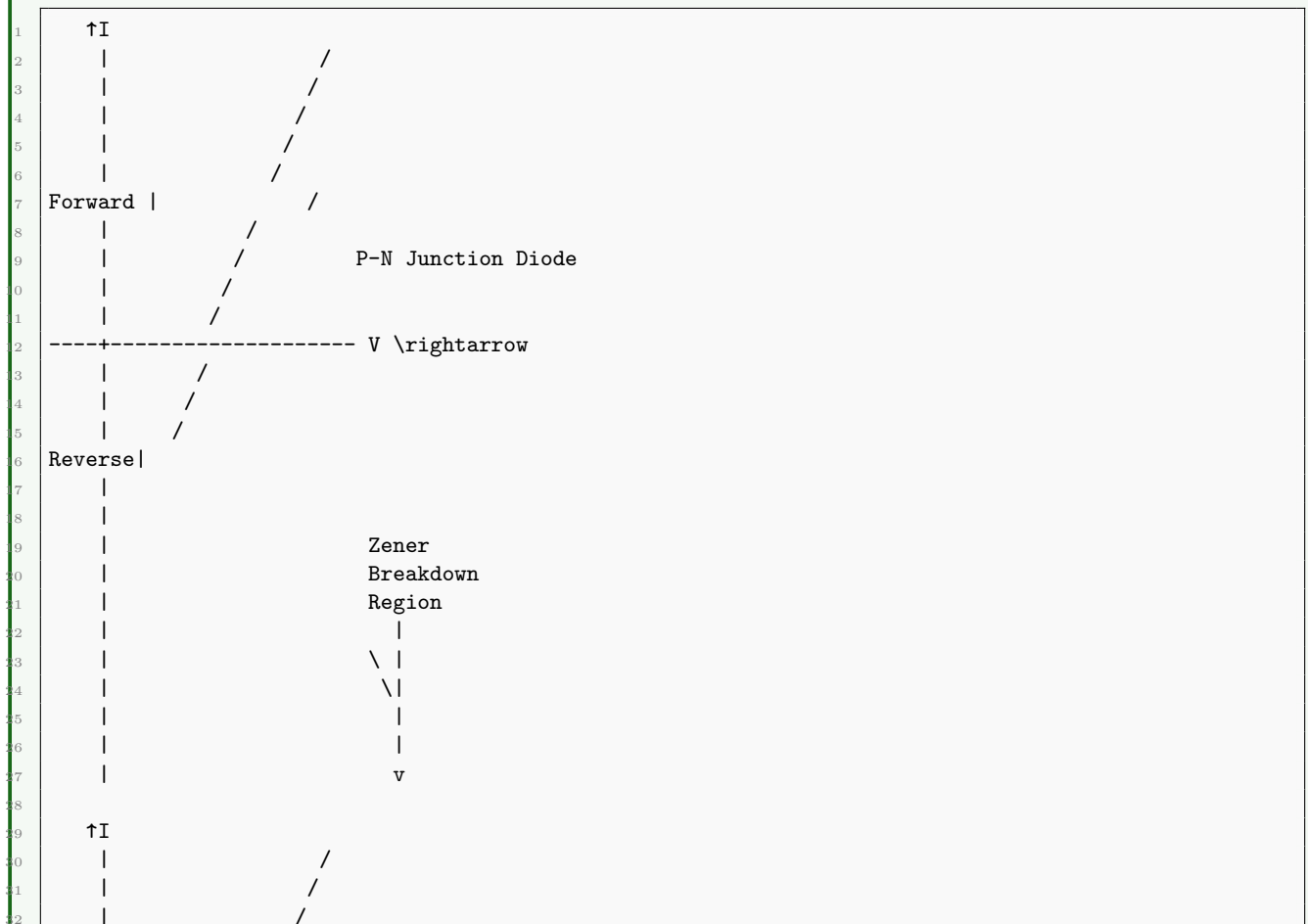
“Population Inversion Creates Coherent Light” (PICL)

### Question 3(a) OR [3 marks]

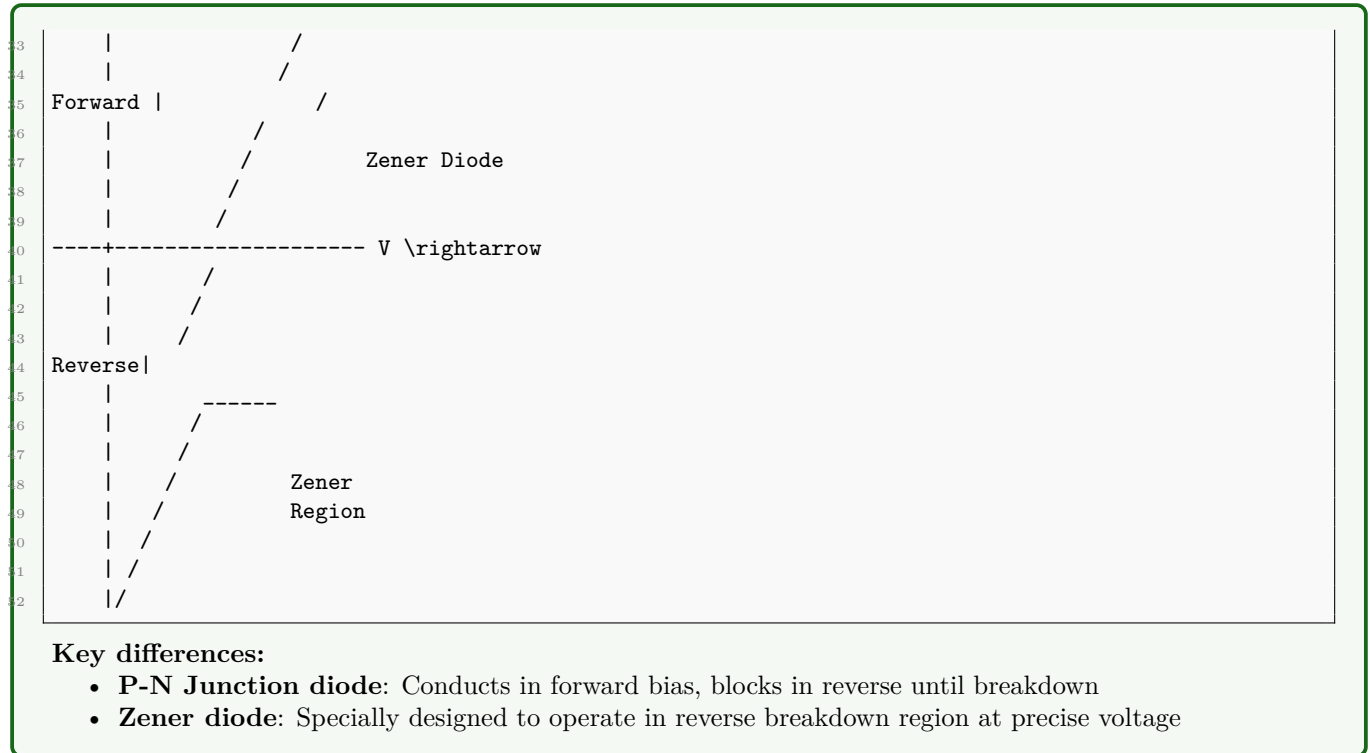
Draw V-I characteristics of P-N junction diode and Zener diode.

#### Solution

##### Diagram:







#### Mnemonic

“Forward Same, Reverse Different” (FSRD)

### Question 3(b) OR [4 marks]

Explain working of P-N junction diode in forward bias with circuit diagram.

#### Solution

##### Diagram:



##### Working in forward bias:

- **Connection:** P-side connected to positive terminal, N-side to negative terminal
- **Depletion region:** Width decreases as applied voltage increases
- **Barrier potential:** Must overcome threshold (0.7V for Si, 0.3V for Ge)
- **Current flow:** Above threshold, current increases exponentially with voltage
- **Majority carriers:** Electrons from N-side and holes from P-side are pushed toward junction
- **Recombination:** Electrons and holes recombine, creating continuous current flow

**Current equation:**  $I = I_0(e^{qV/kT} - 1)$ , where  $I_0$  is reverse saturation current

#### Mnemonic

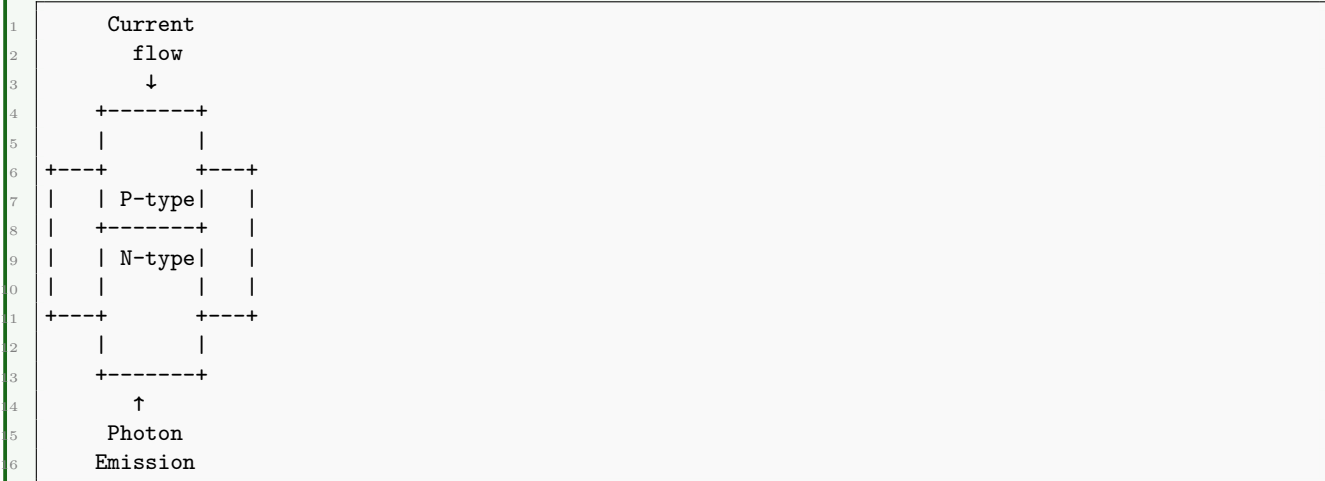
“Positive to P, Reduces Barrier, Current Flows” (PPRBCF)

### Question 3(c) OR [7 marks]

Explain working of Light Emitting diode (LED) and Photodiode with diagram.

## Solution

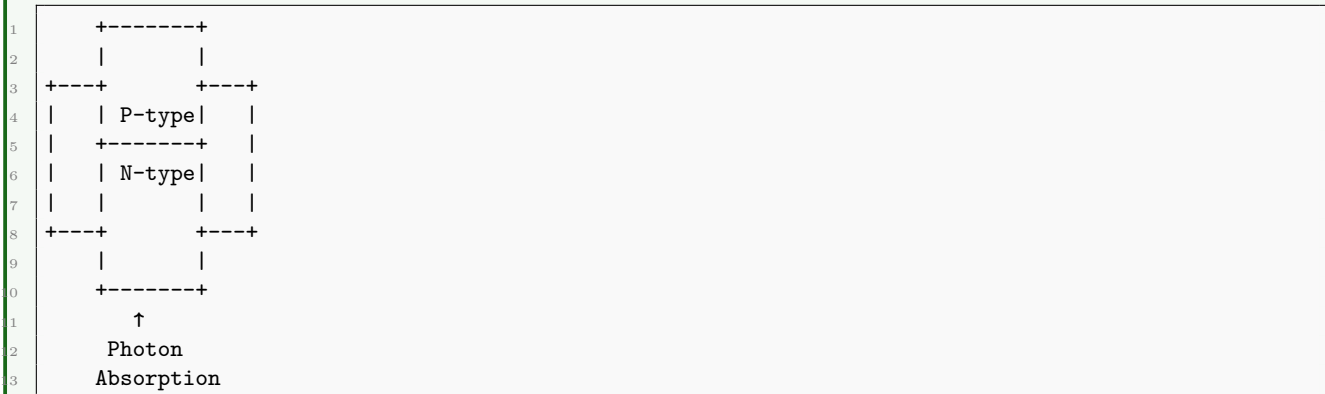
### LED Diagram:



### LED Working:

- **Direct bandgap:** Made of GaAs, GaP compounds with direct bandgap
- **Forward bias:** Applied to inject carriers across junction
- **Recombination:** Electrons from N-side recombine with holes from P-side
- **Photon emission:** Energy released during recombination emitted as photons
- **Wavelength control:** Different materials produce different colors
- **Efficiency:** Modern LEDs achieve 80-90% efficiency

### Photodiode Diagram:



### Photodiode Working:

- **Reverse bias:** Operated in reverse bias typically
- **Light absorption:** Photons absorbed in depletion region
- **Electron-hole pairs:** Created by photon energy
- **Carrier separation:** Electric field separates electrons and holes
- **Current generation:** Photocurrent proportional to light intensity
- **Response time:** Faster in reverse bias due to wider depletion region

### Comparison table:

Parameter	LED	Photodiode
<b>Function</b>	Converts electrical energy to light	Converts light to electrical energy
<b>Bias mode</b>	Forward bias	Reverse bias (typically)
<b>Direction</b>	Energy output (emitter)	Energy input (detector)
<b>Application</b>	Displays, indicators, lighting	Light sensors, optical communications

### Mnemonic

“LEDs Emit, Photodiodes Detect” (LEPD)

### Question 4(a) [3 marks]

Define the following terms: (i) Rectifier efficiency ( ) (ii) Ripple factor ( ) (iii) Voltage regulation

#### Solution

##### Table of Definitions:

Term	Definition
<b>Rectifier efficiency ( )</b>	Ratio of DC power output to AC power input in a rectifier circuit ( $= P_{DC}/P_{AC} \times 100\%$ )
<b>Ripple factor ( )</b>	Ratio of RMS value of AC component to DC component in rectifier output ( $= V_{rms(ac)}/V_{dc}$ )
<b>Voltage regulation</b>	Measure of how well a power supply maintains constant output voltage despite changes in load ( $VR = [(V_{NL} - V_{FL})/V_{FL}] \times 100\%$ )

### Mnemonic

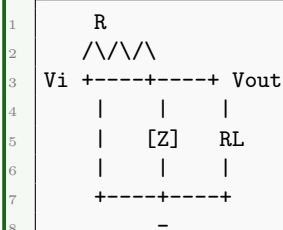
“Efficiency Powers, Ripple Varies, Regulation Stabilizes” (EPRVS)

### Question 4(b) [4 marks]

Explain zener diode as a voltage regulator.

#### Solution

##### Diagram:



##### Working principle:

- **Zener breakdown:** Operates in reverse breakdown region at specific voltage
- **Series resistor:** Limits current and drops excess voltage
- **Parallel connection:** Zener connected in parallel with load
- **Regulation mechanism:**
  - When input voltage increases: More current through Zener, voltage across load remains constant
  - When load current increases: Less current through Zener, voltage remains constant

##### Characteristics:

- **Load regulation:** Maintains constant voltage despite load changes
- **Line regulation:** Maintains constant voltage despite input voltage changes
- **Power rating:** Zener must handle maximum power dissipation ( $P = V_Z \times I_Z$ )
- **Design equation:**  $R = (V_{in} - V_Z)/I_L + I_Z$

### Mnemonic

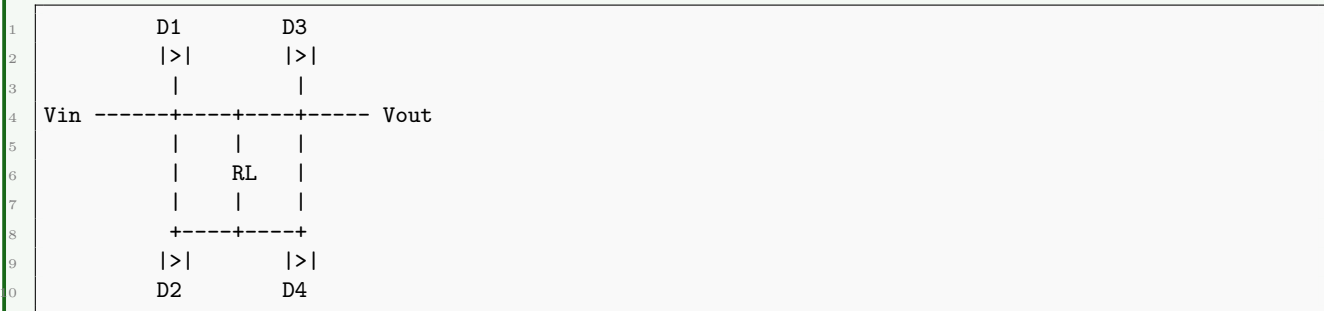
“Zener Shunts Excess Current” (ZSEC)

### Question 4(c) [7 marks]

Explain full wave bridge rectifier with circuit diagram and input-output waveform.

## Solution

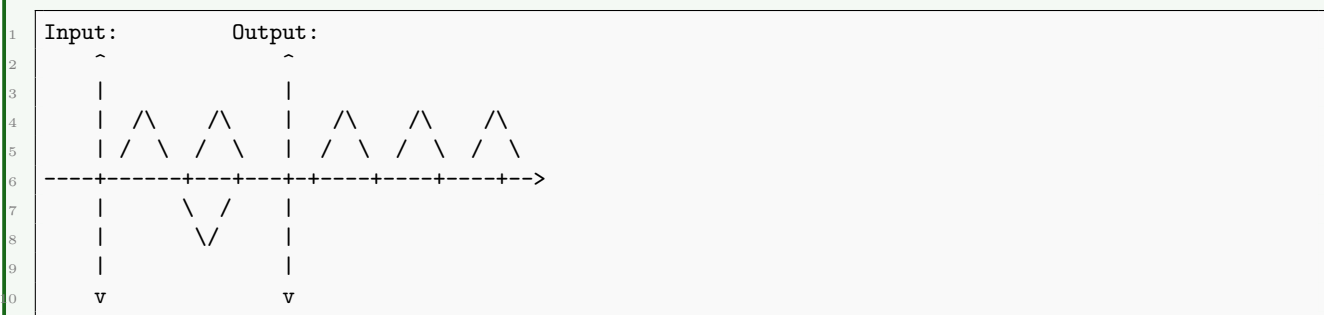
### Circuit Diagram:



### Working principle:

- **First half cycle (positive):** D1 and D4 conduct, D2 and D3 block
- **Second half cycle (negative):** D2 and D3 conduct, D1 and D4 block
- **Both half cycles:** Current flows through load in same direction

### Waveforms:



### Characteristics:

- **Ripple frequency:** Twice the input frequency
- **Output voltage:**  $V_{dc} = 2V_m / \pi \approx 0.636V_m$
- **PIV:** Each diode must withstand  $V_m$
- **Efficiency:** = 81.2%
- **Ripple factor:** = 0.48
- **Uses:** Higher current applications, no center-tapped transformer needed

### Advantages over center-tapped:

- No center-tapped transformer required
- Lower PIV requirement for diodes
- Better transformer utilization

## Mnemonic

“Bridge Brings Both Halves” (BBBH)

## Question 4(a) OR [3 marks]

Give the applications of rectifier.

## Solution

### Applications of Rectifiers:

Application Area	Specific Uses
<b>Power supplies</b>	DC power supplies for electronic devices, battery chargers, adaptors
<b>Industrial applications</b>	Electroplating, welding machines, motor drives, induction heating
<b>Transport systems</b>	Electric locomotives, metro trains, electric vehicles
<b>Renewable energy</b>	Solar inverters, wind power generation

**Consumer electronics**

Mobile phone chargers, laptop adapters, TV power supplies

**Telecommunications**

Base stations, transmission equipment, signal processing devices

### Mnemonic

“Power Perfectly Transformed in Consumer Devices” (PPTICD)

### Question 4(b) OR [4 marks]

Compare half wave, full wave center tapped and full wave bridge rectifier with four parameters.

### Solution

Parameter	Half Wave	Full Wave Center Tapped	Full Wave Bridge
<b>Number of diodes</b>	1	2	4
<b>DC output voltage</b>	$V_m / (0.318V_m)$	$2V_m / (0.636V_m)$	$2V_m / (0.636V_m)$
<b>Ripple frequency</b>	Same as input	Twice the input	Twice the input
<b>Efficiency</b>	40.6%	81.2%	81.2%
<b>Transformer utilization</b>	Poor	Medium (center tap needed)	Good (no center tap)
<b>PIV of diodes</b>	$V_m$	$2V_m$	$V_m$
<b>Ripple factor</b>	1.21	0.48	0.48
<b>Form factor</b>	1.57	1.11	1.11

### Mnemonic

“Half Wastes, Center Tapped Improves, Bridge Optimizes” (HWCTIBO)

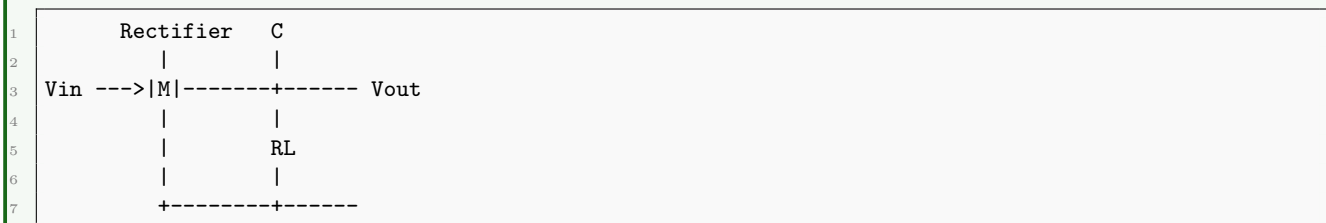
### Question 4(c) OR [7 marks]

Explain Shunt capacitor filter and -filter with circuit diagram.

### Solution

#### Shunt Capacitor Filter:

#### Diagram:



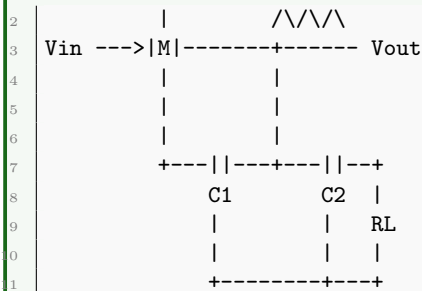
#### Working principle:

- **Charging:** Capacitor charges rapidly during voltage rise in rectifier output
- **Discharging:** Capacitor discharges slowly through load during voltage fall
- **Smoothing effect:** Reduces ripple by storing energy when voltage is high
- **Time constant:** RC should be much larger than ripple period
- **Performance:** Ripple factor  $= 1/(4\sqrt{3}fRC)$

#### -Filter:

#### Diagram:





#### Working principle:

- **First capacitor (C1):** Provides initial filtering like shunt capacitor
- **Choke (L):** Blocks AC components, allows DC to pass
- **Second capacitor (C2):** Further reduces remaining ripple
- **Combined effect:** Acts as cascade of low-pass filters

#### Comparison:

Parameter	Shunt Capacitor Filter	-Filter
<b>Components</b>	Single capacitor	Two capacitors and inductor
<b>Ripple reduction</b>	Moderate	Excellent
<b>Cost</b>	Low	High
<b>Size</b>	Small	Large
<b>Voltage regulation</b>	Poor	Good
<b>Suitable for</b>	Low current applications	High current applications

#### Mnemonic

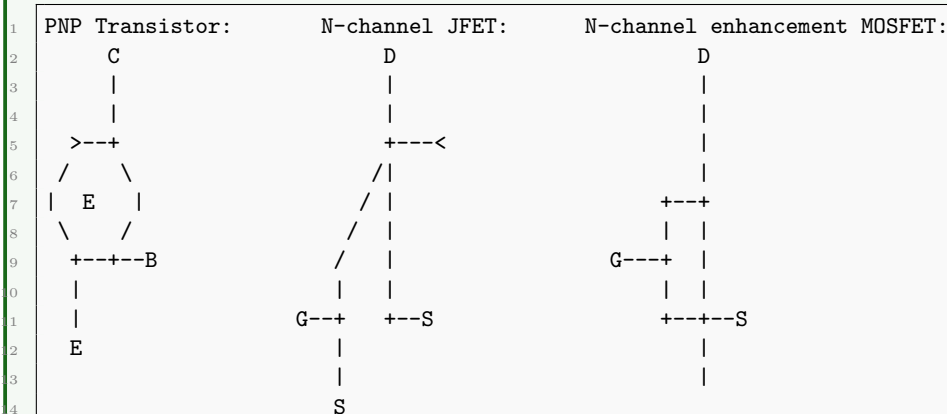
“Capacitor Smooths, Pi-Filter Perfects” (CSPFP)

### Question 5(a) [3 marks]

Draw the symbols of following components: (i) PNP transistor (ii) N channel JFET (iii) N channel enhancement mode MOSFET

#### Solution

##### Diagram:



##### Characteristics:

- **PNP Transistor:** Arrow points inward at emitter
- **N-channel JFET:** Gate controls channel between source and drain
- **N-channel enhancement MOSFET:** Gap in channel, requires positive gate voltage

### Mnemonic

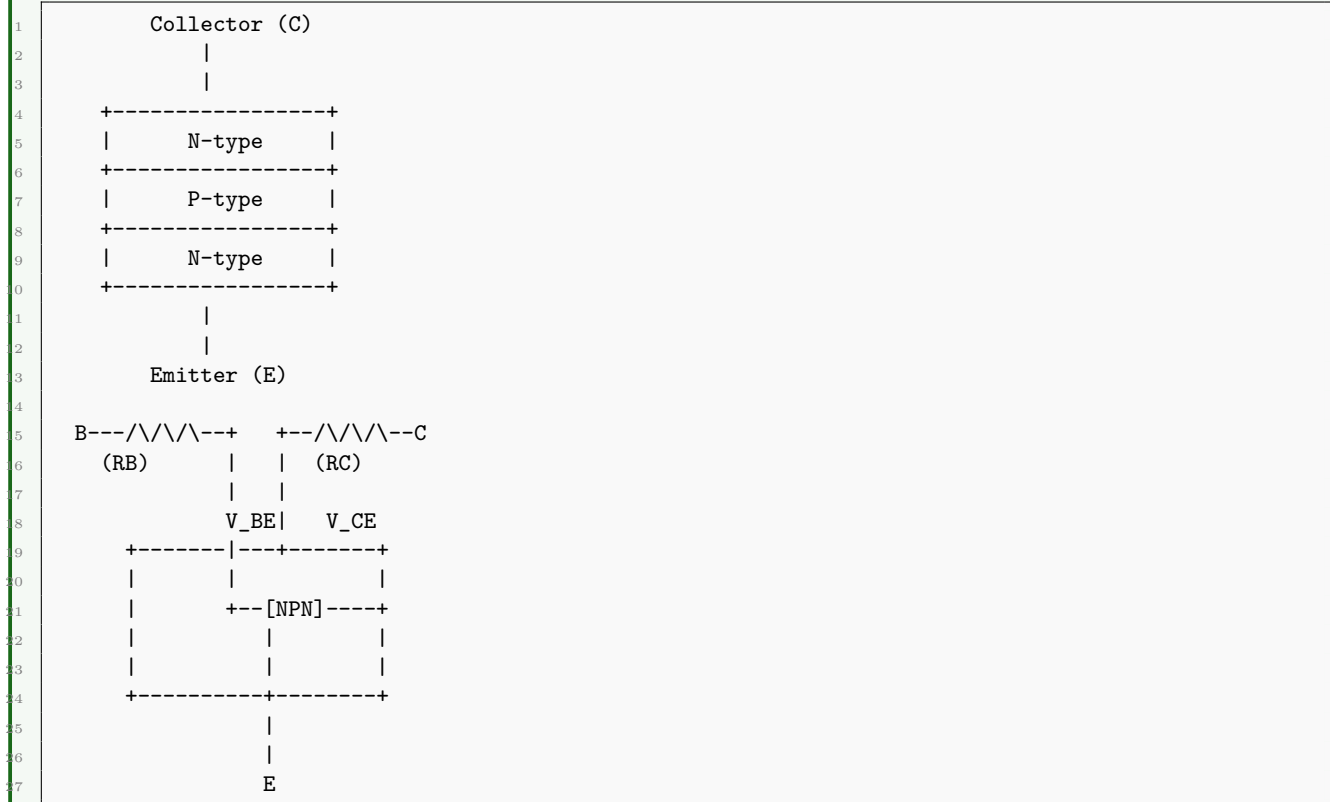
“PNP Points IN, JFET Joins Gates, MOSFET Makes Gaps” (PPIJJGMMG)

### Question 5(b) [4 marks]

Explain working of NPN transistor with diagram.

### Solution

Diagram:



### Working principle:

- **Structure:** Two N-type regions separated by thin P-type region
- **Biasing:** E-B junction forward biased, C-B junction reverse biased
- **Current flow:**
  - Electrons from emitter cross into base
  - ~98% electrons continue to collector due to thin base region
  - ~2% electrons recombine in base region
- **Amplification:** Small base current controls larger collector current
- **Current relationship:**  $I_C = \beta I_B$  (where  $\beta$  is current gain)

### Junction behavior:

- **Emitter-Base junction:** Forward biased, low resistance path
- **Collector-Base junction:** Reverse biased, high resistance path

### Mnemonic

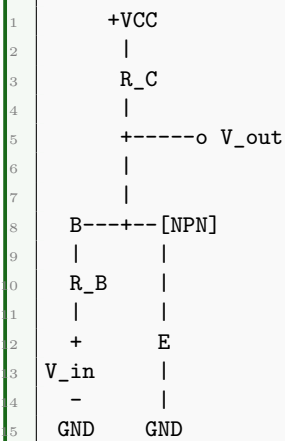
“Electrons Enter, Barely Pause, Collect Above” (EEBPCA)

### Question 5(c) [7 marks]

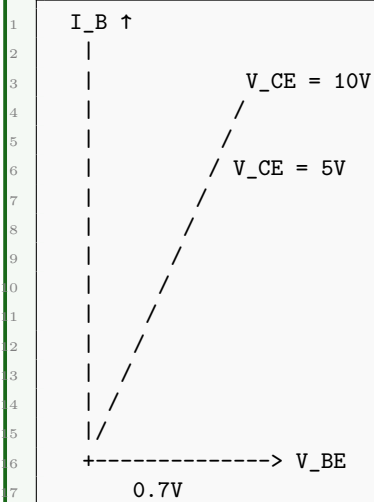
Draw and explain common emitter (CE) transistor with its input output characteristic.

## Solution

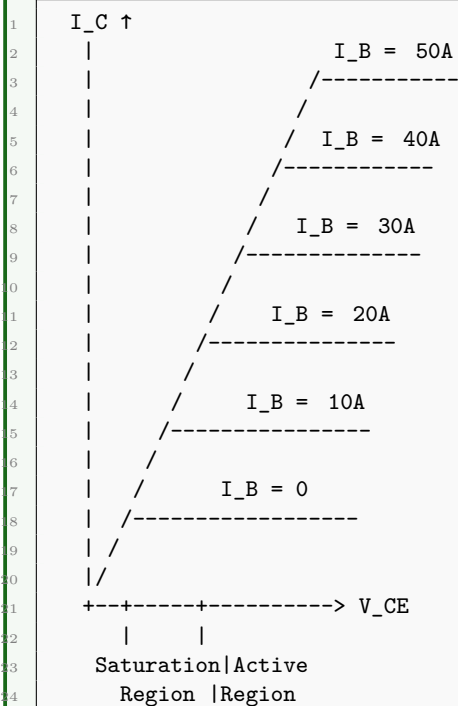
### Circuit Diagram:



### Input Characteristics ( $I_B$ vs $V_{BE}$ with $V_{CE}$ constant):



### Output Characteristics ( $I_C$ vs $V_{CE}$ with $I_B$ constant):



### Operating regions:

- Cut-off:  $I_B \approx 0, I_C \approx 0, \text{transistor OFF}$



- **Active:** E-B junction forward biased, C-B junction reverse biased, linear amplification
- **Saturation:** Both junctions forward biased, transistor fully ON

**Parameters:**

- **Current gain ( $\beta$ ):** Ratio of collector current to base current ( $\beta = I_C/I_B$ )
- **Input resistance:** Ratio of change in  $V_{BE}$  to change in  $I_B$
- **Output resistance:** Ratio of change in  $V_{CE}$  to change in  $I_C$

**Applications:**

- **Amplification:** Voltage, current, and power amplification
- **Switching:** Digital circuits, logic gates
- **Signal processing:** Oscillators, filters, modulators

**Mnemonic**

“Cut-Active-Saturate: Off-Amplify-On” (CASOAO)

**Question 5(a) OR [3 marks]**

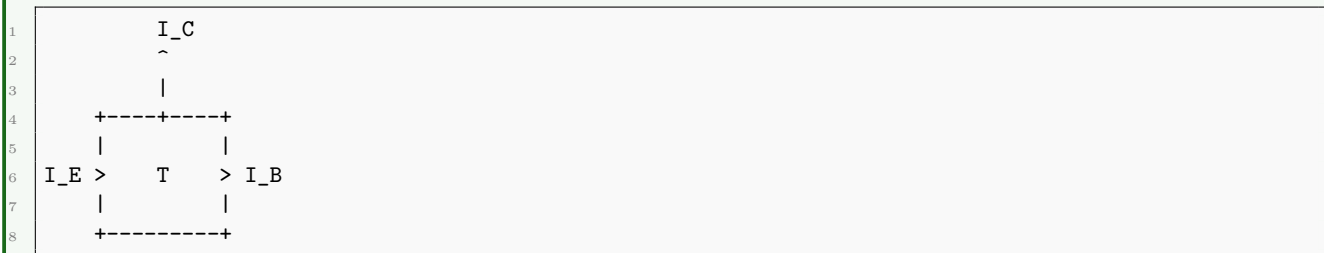
Derive relationship between current gain alpha ( $\alpha$ ) and beta ( $\beta$ ).

**Solution**

**Key definitions:**

- **Alpha ( $\alpha$ ):** Common-base current gain =  $I_C/I_E$
- **Beta ( $\beta$ ):** Common-emitter current gain =  $I_C/I_B$

**Diagram:**



**Current relationship in transistor:**

- $I_E = I_B + I_C$  (Kirchhoff's Current Law)

**Derivation steps:**

1.  $\alpha = I_C/I_E$
2.  $I_E = I_B + I_C$
3.  $\alpha = I_C/(I_B + I_C)$
4.  $\alpha = I_C/I_B$
5.  $I_C = \alpha I_B$
5. Substituting in equation 3:  

$$\alpha = (\alpha I_B)/(I_B + \alpha I_B)$$

$$= \alpha / (1 + \alpha)$$
6. Solving for  $\alpha$ :  $(1 + \alpha) = \alpha + \alpha = 1$   

$$= 1 - \alpha$$

$$= (1 - \alpha)$$

$$= 1 / (1 - \alpha)$$

**Final relationships:**

- $\alpha = 1 / (1 - \beta)$
- $\beta = \alpha / (1 + \alpha)$

**Typical values:**

- $\alpha$  is always less than 1 (typically 0.95 to 0.99)
- $\beta$  typically ranges from 20 to 200

**Mnemonic**

“Alpha Approaches One, Beta Becomes Infinite” (AAOBBI)

Question 5(b) OR [4 marks]

Explain different operating regions for transistor.

Solution

Diagram:

The diagram is a graph with  $I_C$  on the vertical axis and  $V_{CE}$  on the horizontal axis. It is divided into three regions by dashed lines: the Saturation Region (top-left), the Active Region (top-right), and the Cut-off Region (bottom-left). The boundaries are defined by  $I_C = I_{CS}$  (horizontal line in saturation),  $V_{CE} = V_{CE(sat)}$  (vertical line in saturation),  $I_C = 0$  (horizontal line in cut-off), and  $V_{CE} = 0$  (vertical line in cut-off).

Operating regions:

Region	Junction Bias	Characteristics	Applications
Cut-off	E-B: OFF C-B: OFF	<ul style="list-style-type: none"><li><math>I_B \approx 0, I_C \approx 0</math></li><li><math>V_{CE} \approx V_{CC}</math></li><li>Transistor is OFF</li></ul>	Digital circuits (OFF state) Switching applications
Active	E-B: ON C-B: OFF	<ul style="list-style-type: none"><li>Linear relationship between <math>I_C</math> and <math>I_B</math></li><li><math>I_C = \beta I_B</math></li><li>Used for amplification</li></ul>	Analog amplifiers Signal processing
Saturation	E-B: ON C-B: ON	<ul style="list-style-type: none"><li>Both junctions forward biased</li><li>Transistor fully ON</li><li><math>V_{CE} \approx 0.2V</math></li></ul>	Digital circuits (ON state) Switching applications
Breakdown	E-B: OFF C-B: Breakdown	<ul style="list-style-type: none"><li>Exceeds breakdown voltage</li><li>Can damage transistor</li><li>Should be avoided</li></ul>	Avoid this region in normal operation

Mnemonic

“Cut Active Saturate: Off Amplify Switch” (CASOAS)

Question 5(c) OR [7 marks]

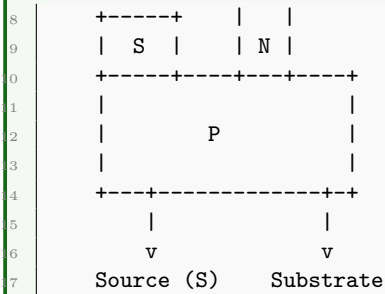
Write a short note on MOSFET.

Solution

MOSFET (Metal Oxide Semiconductor Field Effect Transistor)

Structure Diagram:

The diagram shows a cross-section of a MOSFET. At the top is the Gate (G), represented by a rectangle. Below it is a layer labeled 'v' (oxide). To the right is the Drain (D), represented by a rectangle. Below the oxide layer is a layer labeled 'M' (metal). At the bottom is the Source (S), represented by a rectangle. The channel region is labeled 'O' (oxide). The diagram is enclosed in a dashed box.



#### Types of MOSFETs:

- **Enhancement mode:** Channel does not exist without gate voltage
  - N-channel: Positive gate voltage creates channel
  - P-channel: Negative gate voltage creates channel
- **Depletion mode:** Channel exists without gate voltage
  - N-channel: Negative gate voltage depletes channel
  - P-channel: Positive gate voltage depletes channel

#### Working principle:

- **Insulated gate:** Gate isolated from channel by oxide layer
- **Field effect:** Electric field controls channel conductivity
- **Voltage controlled:** Gate voltage controls drain current
- **No gate current:** Extremely high input impedance

#### Characteristics:

- **Transfer characteristic:**  $I_D$  vs  $V_{GS}$
- **Output characteristic:**  $I_D$  vs  $V_{DS}$
- **Threshold voltage:** Minimum  $V_{GS}$  required to create channel
- **Transconductance:** Change in  $I_D$  per unit change in  $V_{GS}$

#### Advantages over BJT:

- **High input impedance:** Virtually no input current
- **Faster switching:** Lower capacitance, no minority carrier storage
- **Higher packing density:** Smaller size for same function
- **Lower power consumption:** Less heat generation
- **Simpler biasing:** Single polarity supply often sufficient

#### Applications:

- **Digital circuits:** CMOS logic, memory devices
- **Analog circuits:** Amplifiers, current sources
- **Power electronics:** High-power switching
- **RF applications:** Low-noise amplifiers
- **Integrated circuits:** Processors, ASICs

#### Mnemonic

“Metal Oxide Separate Gate Enables Field Control” (MOSGFC)